Receipt date: 07/16/2009

OK TO ENTER: /SA/ (07/20/2009)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No. : 10/579,777

First Named Inventor : Hiraku ISHIKAWA

Filed : Fe

: February 26, 3008 : 1792

TC/A.U. : 17 Examiner : Sh

: Shamim Ahmed

Docket No.

: 101994.57726US

Customer No.

: 23911

Title

: Plasma Film-Forming Apparatus and Plasma Film-Forming Method

Confirmation No. : 5716

REPLY TO OFFICE ACTION

Mail Stop AF

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

The following remarks are respectfully submitted in response to the final Office Action dated April 21, 2009.

The Listing of Claims begins on page 2 of this paper.

Remarks begin on page 5 of this paper.